

10/549849

IC20 Rec'd PCT/PTO 23 SEP 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :  
Jyun IWASHITA et al. : **Mail Stop: PCT**  
Serial No. NEW : Attorney Docket No. 2005\_1513A  
Filed September 23, 2005 :

NEGATIVE RESIST COMPOSITION AND  
METHOD OF FORMING RESIST PATTERN  
[Corresponding to PCT/JP2004/004080  
Filed March 24, 2004]

---

**PRELIMINARY AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows:

ATTACHMENT D }